

**REMARKS**

Claims 1 to 56 are currently pending in the present application.

The Examiner requires restriction to one of the following inventions:

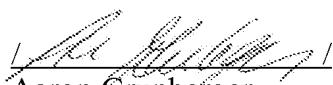
- I. claims 1 to 30 and 41-56 directed to a method of forming a silicon oxide layer; and
- II. claims 31 to 40, drawn to a method for sealing a chamber.

Applicants hereby elect, without traverse, invention I, which corresponds to claims 1 to 30 and 41-56.

Applicants respectfully request an early and favorable action on the merits.

Respectfully submitted,  
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